



RESÒ 7th edition

RESÒ - International Network
for Art Residencies and
Educational Programs

www.reso-network.net

APPLICATION FORM: RESÒ 7 _ RESIDENCY IN at *Fondazione Spinola Banna per l'Arte, Poirino, Italy*

RESÒ is the international residency exchange network for artist-in-residence and educational programs based in Italy's Piedmont region. RESÒ's goal is to foster new relationships, cultural exchanges and creative productions, as well as linking artists with the leading contemporary arts institutions. Since 2010 the project has involved the main art institutions in Piedmont and six foreign institutions. The 7th edition includes: Artport (Tel Aviv) and lugar a dudas (Cali). RESÒ is dedicated to supporting its artist-in-residence in the creation of new works of art and development of research during a term of 6-9 weeks. All of the artists' expenses are covered, including airfare. They will be introduced to the local art scene through a program of meetings, studio visits and talks. The selected artists are expected to hold public presentations of their work towards the end of their residency.

We are hereby pleased to announce the call for applications
for the **RESÒ 7 _ residency IN** program at:
Fondazione Spinola Banna per l'Arte, Poirino, Italy

The **RESÒ 7** residency includes 6-9 weeks to be scheduled between at ***Fondazione Spinola Banna per l'Arte***, Poirino, Italy (dates have to be agreed in line with availability of both the artist and the institution).

For information: www.fondazione-spinola-bannaperlarte.com/new/en/

You are eligible to apply: if you are an artist, curator, researcher, creative professional, (etc.) based in Israel regardless of nationality and age. The conditions of the grant specify that dates of the calendar regarding the residency are fixed and no change can be accepted at any time. Once the artist signs the agreement it is mandatory to respect the dates given. English is required.

Deadline for submissions: 4th of June 2017

Selection: The final selection, made by the Italian institution and based on the Israeli institution's pre-selection given, will be released on 30th of June 2017.

Please submit your application to: artport@artportlv.org

Up to 10 MB per email. If you are submitting more than one email, please indicate as such, for example as subject: *RESÒ residency (your name) 1 of 3 / 2 of 3 / 3 of 3.*

Please fill out (**in English**) this application form by including your:

- Basic / contact information
- Motivation letter for this specific residency
- Professional statement (maximum 2500 keystrokes)
- Check list of submitted work (Images, texts, audios, videos, URLs, etc.)

Along with this application form please also submit your CV and relevant examples of your previous work.

Guidelines for submitting your work:

Images: Submit up to 10, at 100 dpi and medium-sized

Texts: Submit up to 3 examples, published or unpublished

Audio files: Submit up to 3 examples at a duration of up to 10 minutes each

Videos: Submit either URLs if available online or use one of the following upload services *only*: Wetransfer, Dropbox, Rapidshare or yousendit.

All material must be labelled with surname (family) name, followed by an underscore in the file name. For example: Marcus Smith will label his submitted images as *Smith_(title of image).jpg*.



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I am applying for the RESO 7 residency at *Fondazione Spinola Banna* as:

(Please mark the with an X)

- an artist
- a curator
- a critic / writer
- _____ (other, please state)

First name:	
Last name:	
Gender:	male / female
Date of birth:	
Place of birth:	
Nationality:	
Address:	
Telephone:	
Email:	
Website:	

Motivation letter for this specific residency (maximum 3000 keystrokes):

Artist statement (maximum 2500 keystrokes):

A large, empty rectangular box with a thin black border, intended for the artist's statement.

Check list of submitted work (Images, texts, audio files, videos, URLs, etc.)



I confirm this information to be correct. I have also submitted my CV and relevant documentation of my work, such as images, texts, articles, URLs, etc.

I am aware that RESÒ will publish the names and projects of the successful applicants in various publications such as on the RESÒ website, newsletter and annual report.

If my application is successful, I agree to use the residency and grant provided in an appropriate and responsible manner.

Name:

Place and date: